

Homework 1 on Electronic Devices in Silicon CMOS ICs

in the module

EEE201 CMOS Digital Integrated Circuits

1. In the MOS transistors of a digital integrated circuits (ICs), the drain diffusion region has an n -type doping of 10^{17} cm^{-3} on a silicon substrate with the p -type doping of 10^{15} cm^{-3} .

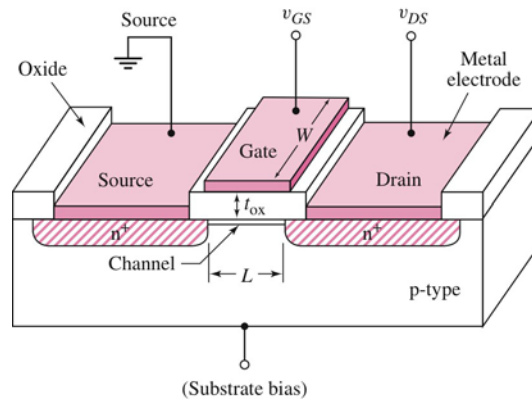


Image from: Donald A. Neamen, Microelectronics: Circuit Analysis & Design, 4th edition, © 2010 McGraw-Hill, USA.

- What is the approximate intrinsic carrier concentration in silicon at room temperature? Hence or otherwise, calculate the **built-in potential V_{bi}** of the **p - n junction** between the p -type substrate and the n -type drain region at room temperature.
- Using the result in (a) or otherwise, calculate the **depletion width** of the **p - n junction** when both the drain and the substrate are not connected to any voltage.
- Using *Matlab* or *Excel*, plot a graph of the **depletion width** when the substrate is connected to ground and the drain voltage V_{DS} varies from +3 V to 0 V.
- If the drain diffusion regions has an area of $400 \mu\text{m} \times 1 \mu\text{m}$, using the result in (b) or otherwise, calculate the **depletion capacitance** of the drain terminal in the open-circuit condition. Assume the sidewall contribution to the depletion capacitance to be negligible.
- If the depth of the drain diffusion regions is $0.2 \mu\text{m}$, calculate the sidewall contribution to the **depletion capacitance** in the open-circuit condition.
- Using *Matlab* or *Excel*, plot a graph of the **depletion capacitance** when the substrate is connected to ground and the drain voltage V_{DS} varies from +3 V to 0 V.

Assume an abrupt junction (i.e. abrupt metallurgical boundary in the **p - n junction**) in all the calculations. Please find out the physical constants (e.g. Boltzmann's constant k_B) from textbooks or reliable websites on the internet.

2. The MOS transistors of the same digital integrated circuits (ICs) described in Q1 has a gate oxide thickness of 76 \AA (i.e. 7.6 nm) and an effective channel length $L = 0.4 \mu\text{m}$.
- Calculate the normalised **gate oxide capacitance C_{ox}** of the MOS transistors. Assume the gate oxide is made of high quality silicon dioxide (SiO_2).
 - Determine the gate-to-source capacitance **C_{GS}** of the MOS transistor operating in the saturation region.

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- (c). Determine the gate-to-drain capacitance C_{GD} of the MOS transistor if it operates in the linear region. How does the value of C_{GD} compare with the **depletion capacitance** of the drain-to-substrate junction?
- (d). It is given the electron mobility for the MOS transistors is $370 \text{ cm}^2/\text{Vs}$ and the **threshold voltage** V_T of the *n*-channel MOS transistors is 0.5 V . Assuming the long-channel approximation, using *Matlab* or *Excel*, plot a graph of the output characteristics (i.e. I_{DS} vs. V_{DS}) of a MOS transistor with a channel width $W = 400 \text{ }\mu\text{m}$ and $L = 0.4 \text{ }\mu\text{m}$ for $V_{GS} = 0.7 \text{ V}$, 1.0 V , 1.5 V , 2.0 V and 2.5 V while V_{DS} varies from 0 V to 3.0 V .
- (e). With the same parameters and the long-channel approximation, using *Matlab* or *Excel*, plot a graph of the transfer characteristics (i.e. I_{DS} vs. V_{GS}) of a MOS transistor of the same size $W/L = 400 \text{ }\mu\text{m}/0.4 \text{ }\mu\text{m}$ for $V_{DS} = 0.2 \text{ V}$, 1.0 V , 2.0 V while V_{GS} varies from 0 V to 3.0 V .
- (f). If aluminium oxide (Al_2O_3) with a dielectric constant of 9.8 is used to replace the silicon dioxide (SiO_2) as the gate dielectric, what would be the normalised **gate oxide capacitance** C_{ox} as compared with that obtained in Q2(a)? Describe qualitatively what would happen to the output characteristics and transfer characteristics of the MOS transistors.

Note: In all the calculations, please show your steps clearly. When you find the values of some material parameters (not provided in the questions), please cite the source(s) explicitly as a footnote or include a section of references at the end.